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(12) United States Design Patent

Chung et al.

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(54) **CLEANING PLATE FOR INDUCING TURBULENT FLOW OF A PROCESSING CHAMBER CLEANING GLASS**

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(**) Term: **14 Years**

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(51) **LOC (9) Cl.** **15-09**
(52) **U.S. Cl.** **D15/144**
(58) **Field of Classification Search** D15/144
See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a cleaning plate for inducing turbulent flow of a processing chamber cleaning glass, as shown.

DESCRIPTION

This invention was made with Government support under DE-EE0003331 awarded by DOE. The Government has certain rights in this invention.

FIG. **1** is a cleaning plate for inducing turbulent flow of a processing chamber cleaning gas.

FIG. **2** is a top plan view of the cleaning plate of FIG. **1**.

FIG. **3** is a bottom isometric view of the cleaning plate of FIG. **1**.

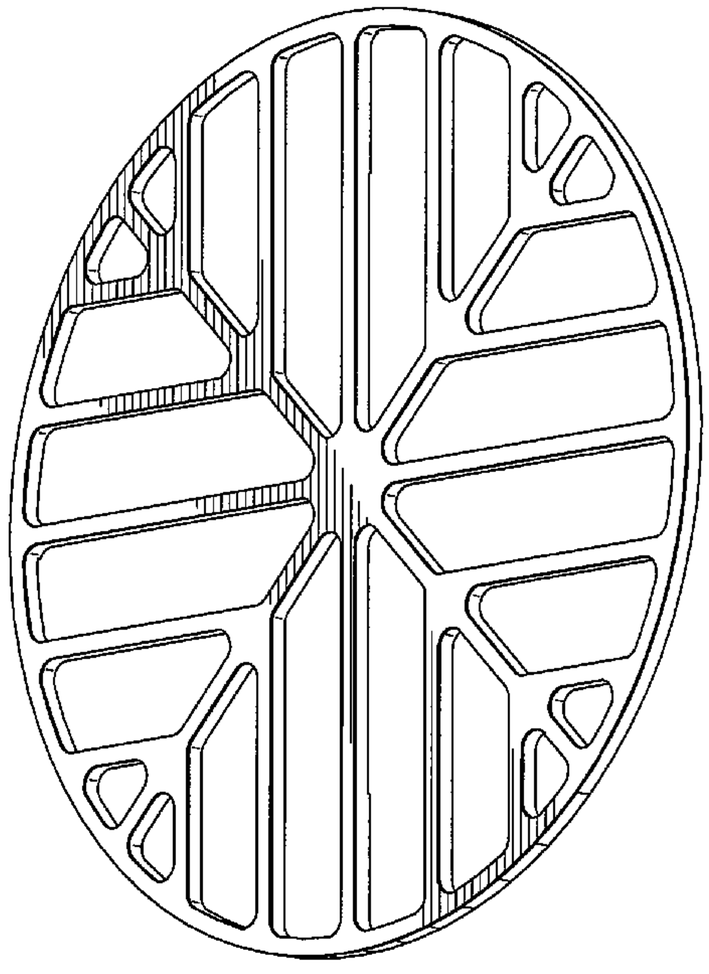
FIG. **4** is a bottom plan view of the cleaning plate of FIG. **1**.

FIG. **5** is a side perspective view of the cleaning plate of **1**; and,

FIG. **6** is an enlarged partial view of FIG. **3**.

The broken lines in the figures form no part of the claimed design.

1 Claim, 5 Drawing Sheets



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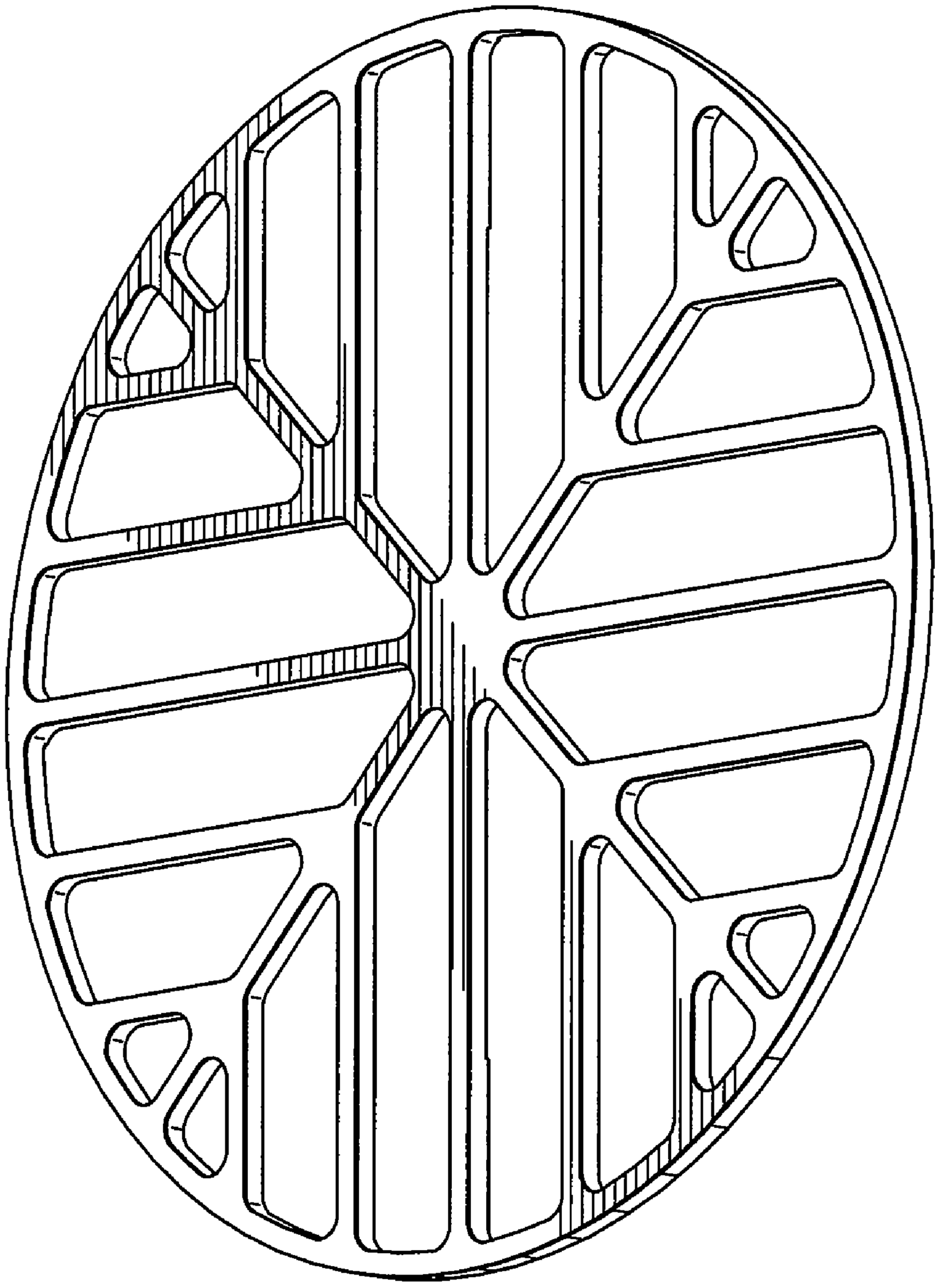

Fig. 1

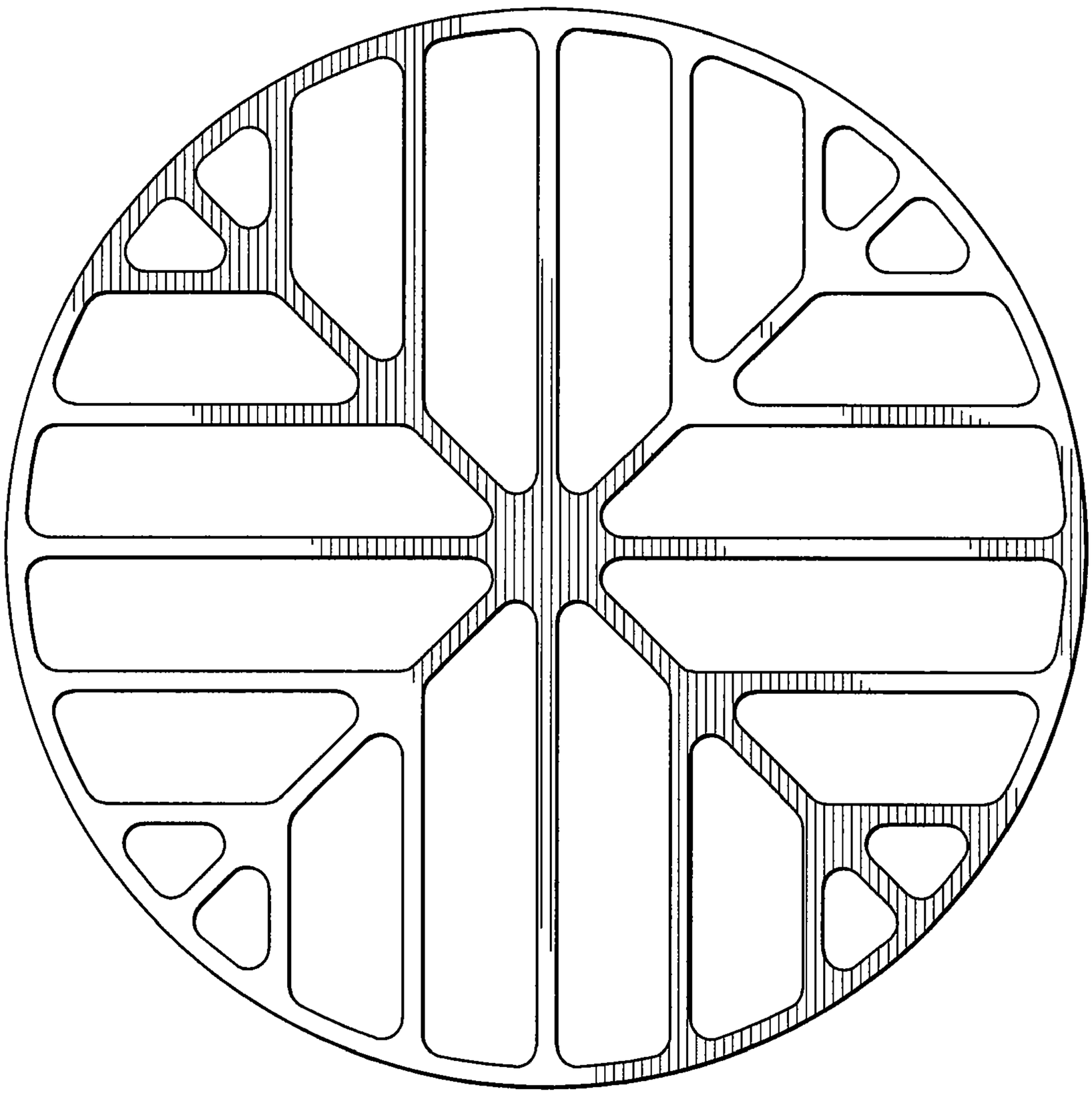

Fig. 2

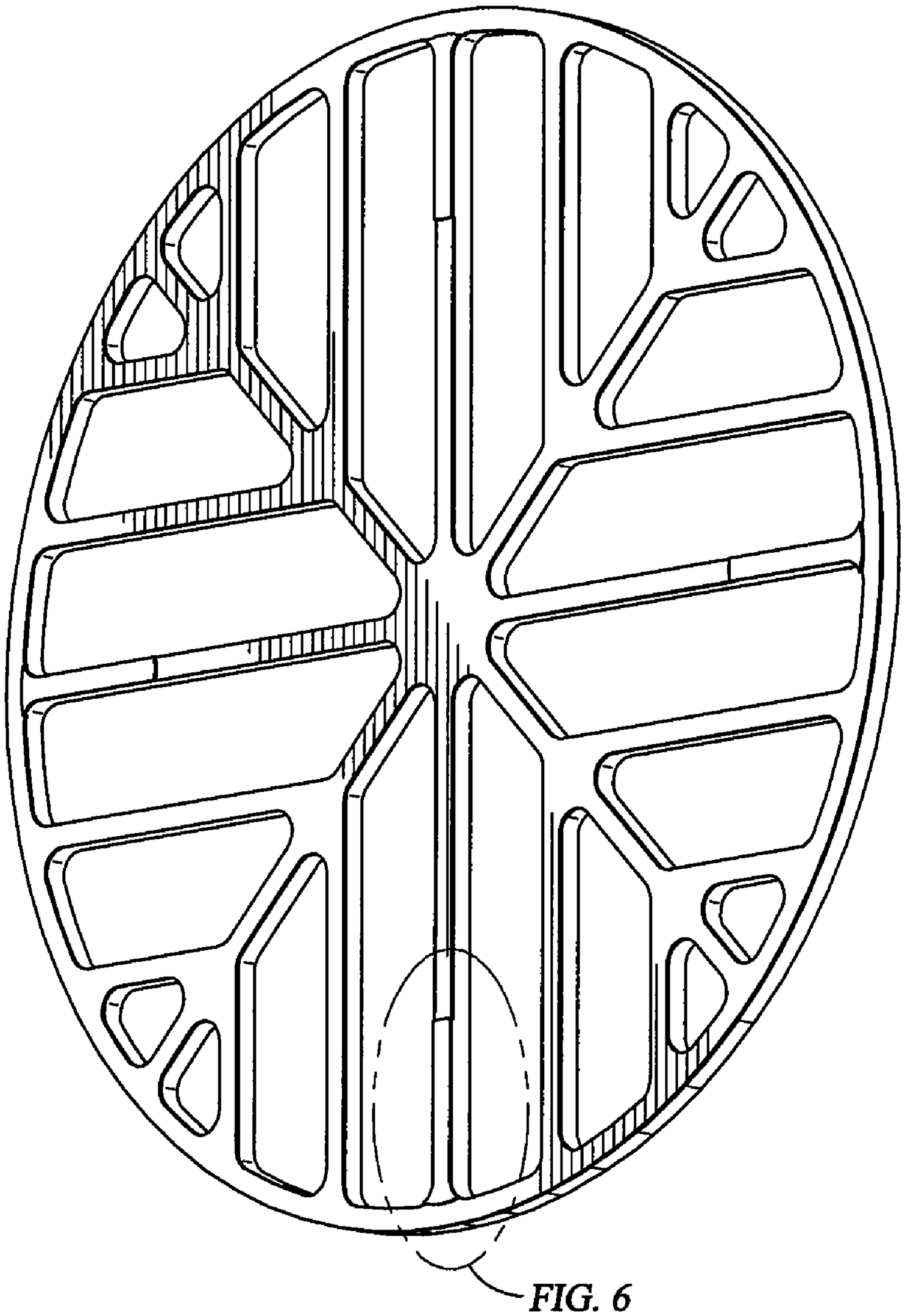

FIG. 6

Fig. 3

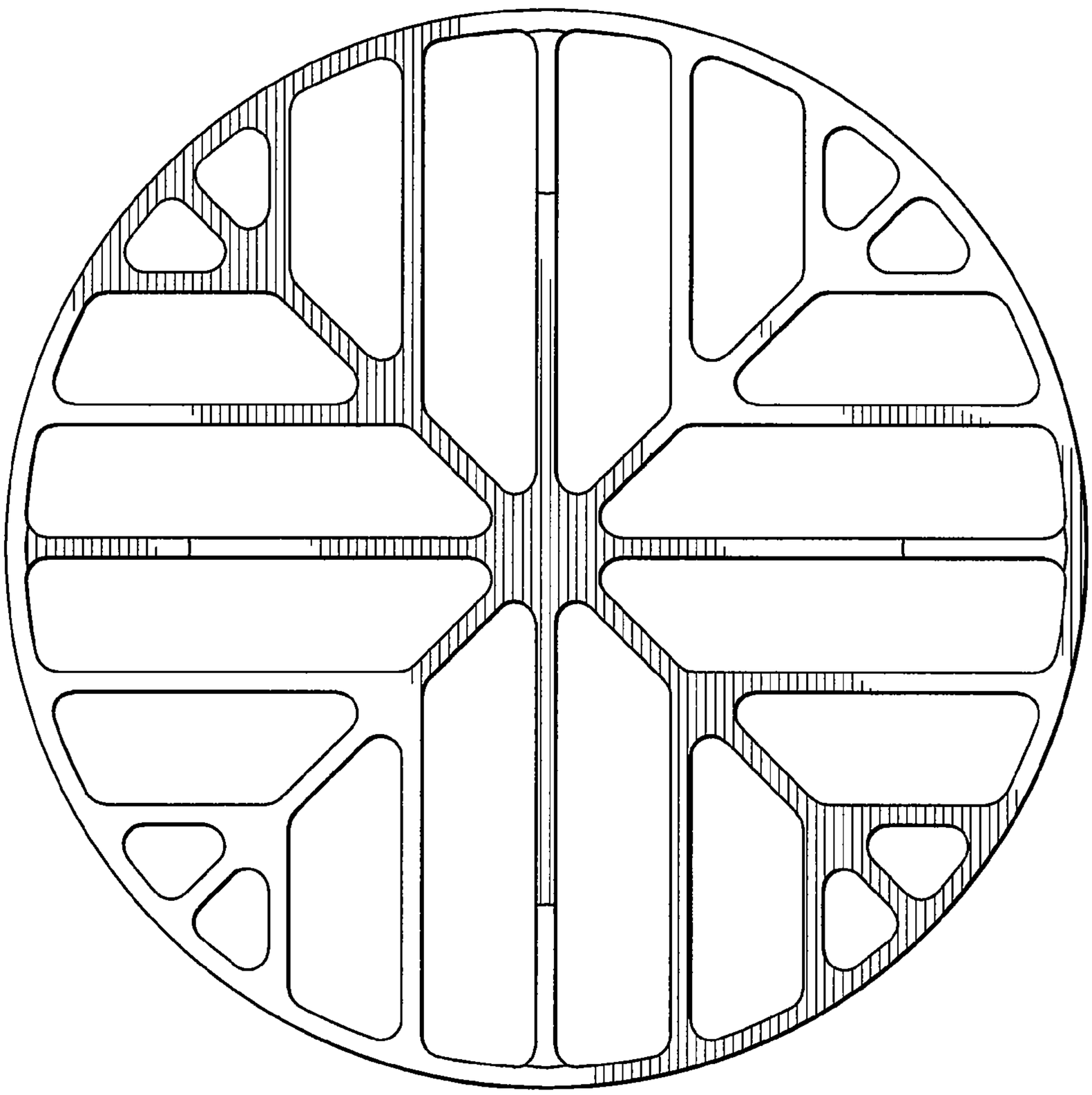

Fig. 4

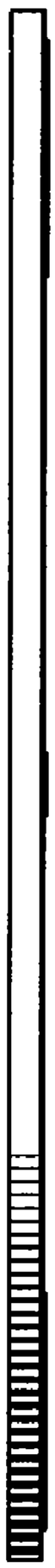

Fig. 5

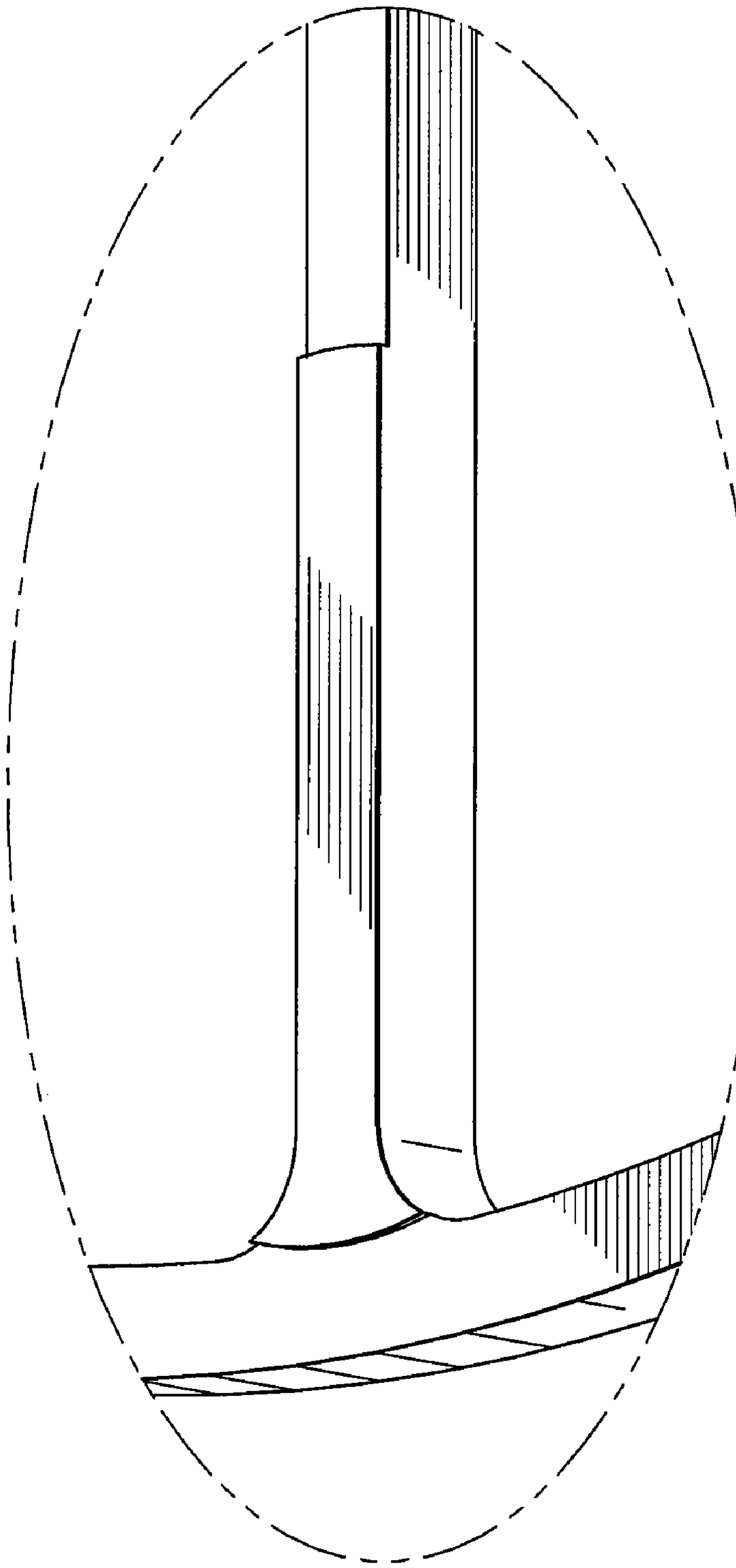

Fig. 6